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LHC Performance Workshops Chamonix 2010/2011/2012 LHC Operation Workshops Evian 2011/2012

Reminder: The Ideal World

Equation of Motion of a Single Particle







relevant parameter in this new context ... 1.6*10⁻¹⁹ C but in LHC we have 2808*1.8*10¹¹ of them and the effect of the fields generated by the beam cannot be neglected anymore.

Second Reminder: (three definitions of impedance)

DC current:



U = R * I Current and Voltage are related by a parameter R that is defined by the properties of the system.





AC current:

 $U = U_0 * \cos(\omega t - \phi_u)$ $I = I_0 * \cos(\omega t - \phi_u)$

or in complex notation:

 $U_C = U_0 * e^{i(\omega t - \phi_U)}$ $I_C = I_0 * e^{i(\omega t - \phi_I)}$

and the physical relevant parameters we get via the real part:

$$U = \operatorname{Re}\{U_C\}, \quad I = \operatorname{Re}\{I_C\}$$

First Definition of Impedance:

Current and Voltage are again related by a parameter that is defined by the properties of the system and that we call IMPEDANCE

$$Z = \frac{U_C}{I_C} = \frac{U_0}{I_0} * e^{-i(\phi_U - \phi_I)}$$

Some general Statements:

A charged particle (bunch) always carries electromagnetic fields



An image current (of opposite sign) is travelling with the bunch along the beam pipe.

In a uniform vacuum tube of perfectly conducting material the image currents are floating without losses and no forces are generated that would act back on the bunch.

Some general Statements:

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Nota bene: there is also a magnetic field (in azimuthal direction) that in ultra relativistic case has the same but opposite force on the particle -> no net effect on the beam at high energy -> strong space charge forces on the particles at low energy. There are no collective instabilities and there is no heating, if the following conditions are fulfilled:

the beam is ultra relativistic the vacuum chamber is smooth the vacuum chamber material is perfectly conducting.

Unfortunately these conditions are not realistic

Examples of vacuum chamber cross sections:







chamber optimised for very different β functions

Due to these non-ideal conditions the fields created are "distorted" and act back on the beam:



A "test-particle" get affected by the fields created by the other particles in front of the same bunch ... or the leading bunches in the beam.

Effect of non-uniform vacuum chambers:





When a charged particle beam traverses a discontinuity in the vacuum chamber fields are generated that have longitudinal & transverse electrical components and change the (long / transverse) energy of the beam.

Examples: HERA-e: Experiment Beam Pipe (HERMES target cell)







Longitudinal Wake Fields:

longitudinal wake function

and normalise to the charge q

test particle: feeling the influence of the wake-field at \tilde{z}

leading particle: creating E-field (wake-field) position z

$$W_{\parallel}(z-\tilde{z}) = \frac{1}{q} \int_{L} E_{\parallel}(s,t-\Delta z/\beta c) ds$$

Integral of E_{\parallel} along interaction length

[units] =V/C

integrating over all particles ahead of the test particle and multiplying by its charge "e" gives the Wake Potential

 $V_{HOM}(\tilde{z}) = -e \int_{\tilde{z}}^{\infty} \lambda(z) W_{\parallel}(z - \tilde{z}) dz \qquad \text{negative sign} \rightarrow \text{decelerating field}$

Total energy loss of bunch: integrate over all slices $d\tilde{z}$

potential

$$\Delta U_{HOM}(\tilde{z}) = -\int_{-\infty}^{\infty} e\lambda(\tilde{z}) d\tilde{z} \int_{\tilde{z}}^{\infty} \lambda(z) W_{\parallel}(z-\tilde{z}) dz$$

Longitudinal Wake Fields:

Wake functions describe higher order mode losses (HOM) in time domain.

A fully equivalent description is obtained in frequency domain.

$$V_{HOM}(\tilde{z}) = -e \int_{\tilde{z}}^{\infty} \lambda(z) W_{\parallel}(z - \tilde{z}) dz$$

replace the charge density by the instantaneous current

$$I(\tilde{z},t) = \hat{I}_0 e^{i(k\tilde{z}-\omega t)}$$

$$V_{HOM}(\tilde{z},t) = -\frac{1}{c\beta} \int_{\tilde{z}}^{\infty} I(\tilde{z},t + \frac{\Delta z}{c\beta}) W_{\parallel}(\Delta z) dz$$

$$V_{HOM}(t,\omega) = -I(t,\omega)\frac{1}{c\beta}\int_{-\infty}^{\infty} e^{-i\omega\Delta z/c\beta}W_{\parallel}(z-\tilde{z}) d\Delta z$$

Second Definition of Impedance: $Z_{II}(\omega)$

The longitudinal coupling impedance relates the beam current to the induced Voltage, that is created by the wake fields and that acts back on the beam.

$$V_{HOM}(t,\omega) = -I(t,\omega)Z_{\parallel}(\omega)$$

Impedance of the vacuum components is the Fourier Transform of the Wake Fields left behind the beam

Two equivalent descriptions:

Interaction of the (test-) particle and the generated (wake-) field (... time domain)

Like in case of cavities: sudden changes in vacuum chamber cross section act like "cavities" -> *representation of frequency dependent impedances (frequency domain).*

frequency spectrum of the beam <--> mode spectrum of the "cavity"

-> induced voltage: $V(\omega) = -Z(\omega) * I(\omega)$



Field lines of a resistive wall wake field generated by a point charge q (court. K. Bane, 1991)

Nota bene:

the minus sign indicates energy loss of the particles

the impedance depends on material and geometry of each piece of vacuum chamber the coupling between beam and structure depends on the frequency spectrum of both ... and so e.g. on the bunch length !!

Wake Fields and Cavity Quality Factor Q:



ext. force inertial force damping restoring force



Resonance in mechanical Oscillations (Gerthsen et al) for different damping

small damping (i.e. small energy losses in the system) leads to narrow resonance width

Optimising the Cavity Design:

go for small losses, e.g. s.c. cavities

Q factor:

$$Q = 2\pi \frac{Stored \ Energy \ in \ the \ Cavity}{Energy \ Loss \ per \ Period}$$
$$= \omega_0 \frac{W}{P_{loss}}$$



Wake Fields and Cavity Quality Factor Q:



The impedance of a special vacuum component can be broad band ($Q \approx 1$), sudden change of chamber size or narrow band (Q >> 1), the cavities (!)

narrow band impedances have a small frequency band, but exist for a long time ... they can act even on other bunches or the same bunch after some turns -> multi bunch instabilities

broad impedances have a broad frequency band, decay fast
 -> single bunch instabilities & heating !!

Wake Fields and Cavity Quality Factor Q:

narrow band impedances

Cavities, Roman Pots, bad flange connections kicker chambers (ceramic) -> shielding by RF-Fingers





forward spectrometer "ALFA"



Transverse Wakefields and Panofsky-Wenzel Theorem

Transverse Forces acting on particles are generated when a bunch is travelling off-centre through a non-uniform structure they only can be induced if there is a longitudinal wake function !!



corresponding impedance:

$$Z_{\perp}(\omega) = \frac{-i}{c\beta} \int_{-\infty}^{\infty} e^{-i\omega\Delta z/c\beta} W_{\perp}(\Delta z) d\Delta z$$

Transverse Impedance, [] = Ω/m

Transverse Wakefields and Panofsky-Wenzel Theorem

Transverse Impedance is imaginary -> transverse amplitude grows but particle (i.e. bunch) energy stays constant

we will observe no heating but bunch instabilities

Panofsky-Wenzel Theorem:

the longitudinal gradient of the transverse force is given by the transverse gradient of the long. force





Longitudinal Impedance of single Elements: Collimators

broad impedances

vacuum chamber cross sections, collimators
-> tapering



sharp temperature increase at injection & ramp slow decrease with decaying beam current

sometimes reaching the damage level



beam screen deformation at injecton collimator

Total Resistive Impedance: Loss Factor

... a quantity to measure or describe on beam (!) the total resistive impedance (over all frequencies)

$$k_{HOM} = \frac{\Delta U_{HOM}}{e^2 N_b^2}$$
 where $\Delta U_{HOM} = energy \ loss \ of \ the \ bunch N_b = number \ of \ particles \ in \ the \ bunch$

 k_{HOM} is – clearly – related to the long. wake function:

$$k_{HOM} = \frac{1}{N_b^2} \int_{-\infty}^{\infty} \lambda(\tilde{z}) d\tilde{z} \int_{\tilde{z}}^{\infty} \lambda(z) W_{\parallel}(z - \tilde{z}) dz$$

and defines the power loss of the beam

 $P_{HOM} = k_{HOM} \frac{I_0^2}{f_0 n_b} = k_{HOM} \frac{I_0}{f_0} \frac{I_0}{n_b} \qquad \dots \text{ remember Ohm: } \mathbf{P} = \mathbf{R}\mathbf{I}^2$

and it depends strongly on the bunch length



Longitudinal Impedance of Single Elements: Collimators

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"Despite active cooling, TCTVBs in IR8 consistently heat by around 10 degrees"

→ Worry if bunch length is reduced in physics, but should be replaced by TCTPs after LS1



Loss Factor Bunch Number & Bunch Length





The loss factor depends on the average beam current I_0 , the number of bunches the current is distributed n_b , the size of the accelerator f_0 and the bunch length !!!

Vacuum chamber components behave like cavities -> represent frequency dependent impedances With the given frequency spectrum of the beam strong coupling to the vacuum components can appear if impedance and beam have a large component at the same frequency. -> loss factor and heating depend strongly on bunch length

 $V(\omega) = -Z(\omega) * I(\omega)$

LHC bunch length control during acceleration

adiabatic damping (= $E^{1/4}$) increase in Voltage (= $V_{rf}^{1/2}$) counter act via rf noise to keep $\sigma_l \approx 1.2$ ns





Example: Luminosity run at LHC

$$\beta_{x,y} = 0.55 m \qquad f_0 = 11.245 \, kHz$$

$$\varepsilon_{x,y} = 5*10^{-10} \, rad \, m \qquad n_b = 2808$$

$$\sigma_{x,y} = 17 \, \mu m \qquad L = \frac{1}{4\pi e^2 f_0 n_b} * \frac{I_{p1} I_{p2}}{\sigma_x \sigma_y}$$

 $I_{p} = 584 \, mA$

$$L = 1.0 * 10^{34} / cm^2 s$$

LHC Bunch Length Effect



Effect of bunch length on HOM heating

Power lost by the beam in a device of impedance Z_{long} (Calculation for LHC, M=2808 bunches $N_b=1.15 \ 10^{11} \text{ p/b}$)

$$P_{loss} = 2(eMN_b f_{rev})^2 \left(\sum_{p=1}^{\infty} \text{Re}\left[Z_{long}(2\pi pMf_{rev})\right] \times Powerspectrum(2\pi pMf_{rev})\right)$$



court. E. Metral

Phase Shift due to Impedance Effects





energy loss has to be compensated by the RF system and leads to change in synchr. phase

 $\Delta U_{HOM} = eN_bV_{rf}\sin(\phi_s - \phi_{s0}) \qquad \text{where } \phi_{s0} = \text{synchr. phase at small (zero) current}$ energy loss depends on the stored beam current and the number of bunches energy loss leads to heating of chamber components and depends strongly on the bunch length.



Example: Temperature increase of LHC injection kickers

LHC MKI8 Heating a cavity like object





Impedances in an Accelerator

LHC beam screen, with Cu coating (!)

Resistive Wall Impedance:

$$\frac{Z_{\parallel}(\omega_n)}{n} = (1+i)\frac{\overline{R}}{n r_w \sigma \delta_{skin}}$$

 $r_w = vacuum chamber radius$ $\delta_{skin} = skin depth$ $n = \omega_n / \omega_0$



improve your vacuum chamber conductivity

Cavity-like Impedance:

$$\frac{1}{Z_{\parallel}(\omega)} = \frac{1}{R_s} (1 + iQ \frac{\omega^2 - \omega_r^2}{\omega \omega_r})$$

Q = cavity quality factor $R_s = cavity shunt impedance$ $\omega_r = resonance frequency$ cavities cannot be avoided ... but cavity-like objects -> shielding



Effect of bunch length on HOM heating: Beam Screen Temperature & Cryo Load





Temperature increase (Peak - before injection) for 1092 bunches:

- *Maxi:* Δ*T* = +4.5*K* (1836, short bunch: 1.12ns-1.14ns)
- Avg: $\Delta T = +3.6 K$
- Mini: ΔT = + 2.6K (1859, longer bunch:1.22ns-1.27ns)
- About 2.0K for injection, rest for ramp effect

Effect of bunch length on HOM heating: Beam Screen Temperature & Cryo Load



Effect of bunch length on HOM heating: Beam Screen Temperature & Cryo Load

Valve control of CRYO to compensate for beam screen heating during 25ns scrubbing we got up to 100% of possible He flow -> at the limit



Reducing the Narrow Band Impedance

avoid cavity like objects ... or shield them by metallic stripes (Kicker example) or "RF-fingers"

example: injection kicker: ceramic chamber & metallic stripes any kind of bellows connections



strong heating observed in some bellows investigation via x-ray-photograph



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